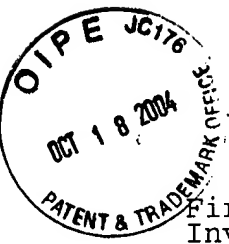


2625  
41



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named  
Inventor : Stanislav V. Aleshin et al.

Appln. No.: 09/879,664

Filed : June 12, 2001

For : MASK CORRECTION FOR  
PHOTOLITHOGRAPHIC PROCESSES

Docket No.: 01-026/L13.12-0149

Group Art Unit: 2625

Examiner: Sheela C.  
Chawan

**AMENDMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

I HEREBY CERTIFY THAT THIS PAPER IS BEING  
SENT BY U.S. MAIL, FIRST CLASS, TO THE  
COMMISSIONER FOR PATENTS, P.O. BOX 1450,  
ALEXANDRIA, VA 22313-1450, THIS

13 DAY OF October, 2004  
Don D. Don  
PATENT ATTORNEY

Sir:

This is in response to the Office Action dated July 23,  
2004. Please amend the above-identified application as follows:

**RECEIVED**

OCT 21 2004

Technology Center 2600